

Amendment to the Specification:

Please make the following change to the specification:

On page 2,

This is a divisional application of USSN 10/001,727 filed December 5, 2001, which is a
continuation-in-part of the patent application USSN 10/000,854 filed October 24, 2001 entitled
“Scanning Techniques in Selective Deposition Modeling.”